## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Ricky Amos, et al.

**Examiner:** 

Matthew C. Landau

Serial No:

09/995,031

**Art Unit:** 

2815

Filed:

November 29, 2001

**Docket:** 

YOR920010633US1 (19031)

For: HIGH TEMPERATURE PROCESSING COMPATIBLE METAL GATE ELECTRODE

FOR pFETs AND METHOD FOR FABRICATION

Confirmation No: 9669

Dated:

June 23, 2008

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

## **RESPONSE UNDER 37 C.F.R. § 1.116**

Sir:

In response to the Final Rejection dated April 24, 2008, Applicants respectfully request that the following amendments and remarks be entered as of record in the above-identified patent application.

## **CERTIFICATE OF ELECTRONIC FILING**

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on June 23, 2008.

Dated: June 23, 2008

Harry Andrew Hild Jr.